

UNIT-V

Special purpose Devices

Zener diode: A special purpose, PN junction semiconductor device, which is designed to operate in reverse breakdown region is said to be "Zener diode".

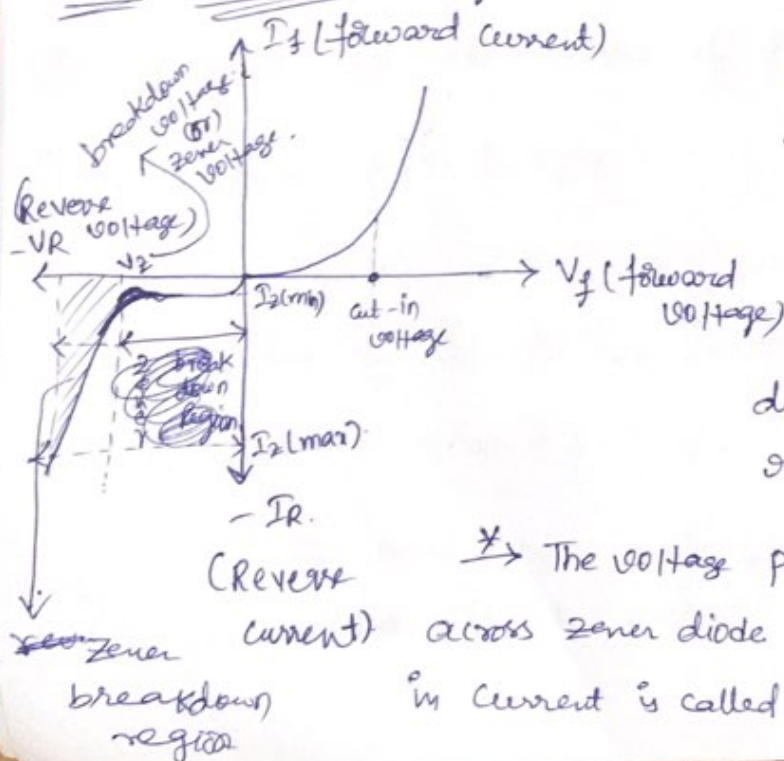
→ Zener diode is heavily doped when compared with PN junction diode.

Symbol ∴ Anode Cathode.



→ electric current in Zener diode flows from both Anode & Cathode

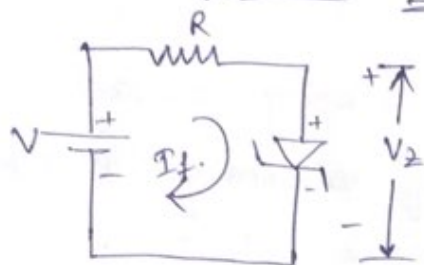
V-I characteristics of Zener diode ∴



→ Zener diode functions like a PN junction diode when forward biased and behaves differently when reverse biased.

* → The voltage point at which voltage drops across Zener diode is const & there is rise in current is called "Zener voltage V_Z ".

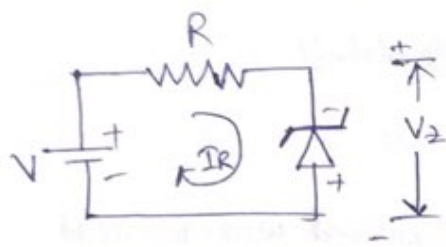
Case (1): forward biasing of Zener diode:-



→ Zener diode is forward biased by connecting anode of Zener diode to (+ve) terminal of battery and Cathode to (-ve) terminal.

→ Forward biased Zener diode behaves like forward biased PN junction diode.

Case (2): Reverse biased Zener diode:-



→ Zener diode is reverse biased by connecting Anode to (-ve) terminal & Cathode to (+ve) terminal of battery.

→ When reverse ^{bias} voltage is applied to Zener diode, only a small amount of current flows through diode, until the Zener voltage (V_z).

→ When reverse bias voltage reaches to Zener voltage, then it allows large amount of current to flow through it.

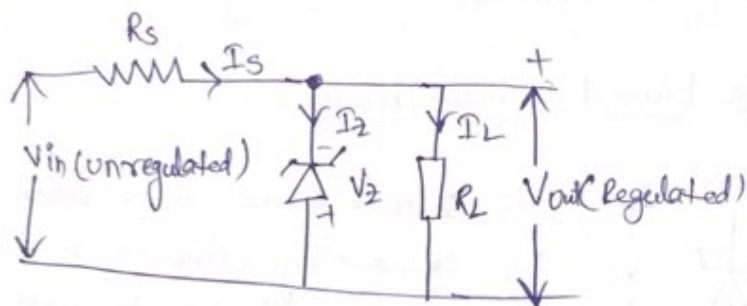
→ At this point, small variation in reverse bias voltage causes ~~large~~ sudden increase in current.

→ A breakdown known as "Zener breakdown" occurs as a result of this sudden increase in current. The reverse current must be in b/w $I_{z(min)}$ & $I_{z(max)}$ to operate Zener diode in breakdown region.

Zener diode as a voltage Regulator:-

Voltage Regulation:- The process of keeping constant voltage across the load regardless of variation of i/p voltage (or) load current is called "voltage regulation".

→ Zener diode has the ability to maintain constant voltage across load.



→ Zener diode is always reverse biased w.r.t input voltage V_{in}

→ The Resistance R_s (Series resistor or current limiting resistor) is used to limit reverse current through Zener diode.

→ V_{in} & R_s are selected in such a way that diode should operate in "breakdown region".

→ voltage across diode in breakdown region is called as Zener voltage V_z , and $V_z = V_{out}$

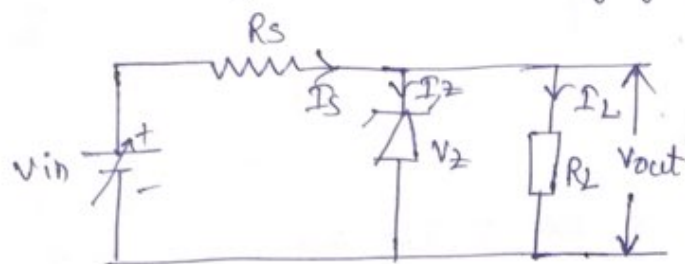
→ if $V_{out} < V_z$ then diode doesn't conduct and hence $I_L = I_s$, ($I_z = 0$)

→ if $V_o \geq V_z$ then diode starts conducting $I_s = I_z + I_L$.

→ Zener diode as voltage regulator is explained in following two cases.

- ① Regulation with varying input voltage V_{in}
- ② Regulation with varying load resistance R_L

Case (1): Regulation with varying input voltage V_{in} .



$$I_S = I_Z + I_L \text{ approx}$$

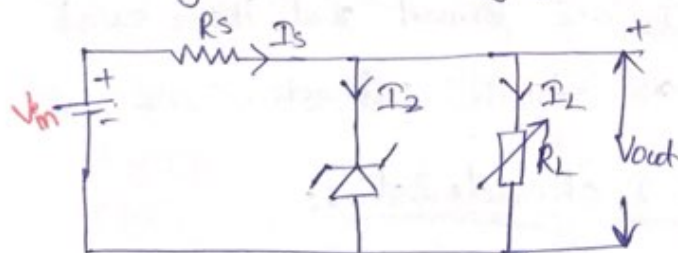
$$5 = 3 + 2$$

$$6 = 4 + 2$$

$$4 = 2 + 2$$

- As i/p voltage increases, i/p current I_S also increases.
- This increases the current through Zener diode I_Z without affecting I_L , thereby keeping V_{out} constant.
- As i/p voltage decreases, i/p current I_S also decreases.
- This decreases the I_Z without affecting I_L , thereby keeping V_{out} constant.

Case (2): Regulation with varying load resistance R_L .



$$I_S = I_Z + I_L \text{ approx.}$$

$$5 = 3 + 2$$

$$\text{if } I_L \uparrow \Rightarrow 5 = 2 + 3$$

$$\text{if } I_L \downarrow \Rightarrow 5 = 4 + 1$$

- if R_L increases then I_L decreases,
- This increases I_Z , as a result the i/p current I_S remains constant, thereby keeping V_{out} constant.
- If R_L decreases then I_L increases,
- This decreases I_Z , as a result the i/p current I_S remains constant, thereby keeping V_{out} constant.

SCR : (silicon Controlled Rectifier)

→ SCR belongs to Thyristor family.

Definition: A silicon semiconductor device with 3 junctions, which can convert AC signal into pulsating DC signal, and can control the amount of signal to be ~~Controlled~~ converted is known as "SCR".

Construction & symbol:

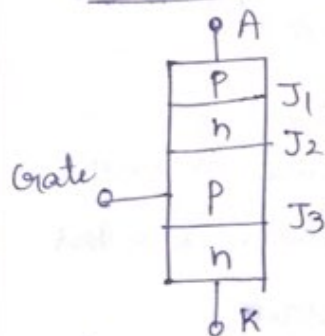


fig: Constructional structure



→ It is constructed using two P-type & two n-type semiconductors, which are arranged as shown in above fig

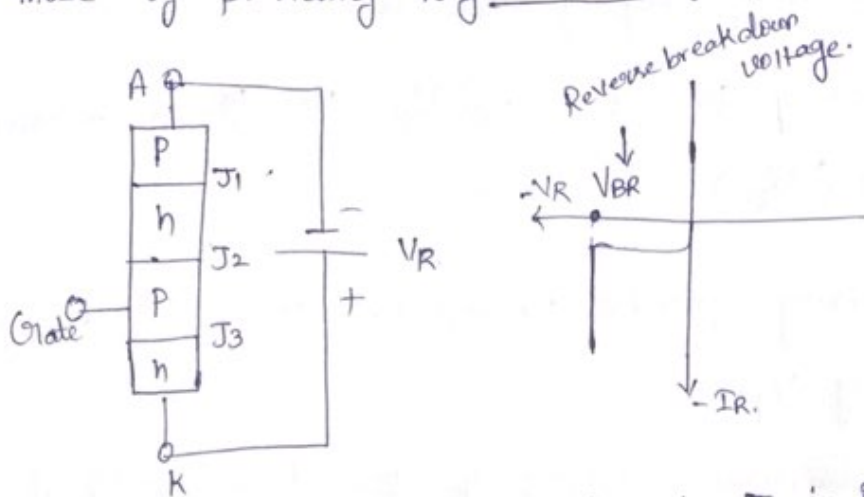
→ As there are 4 layers of semiconductors, 3 junctions named as J_1 , J_2 , J_3 are formed, and there exist 3 terminals named as Anode, Cathode, Gate.

Working principle & V-I characteristics:

→ There are 3 modes of operations for SCR

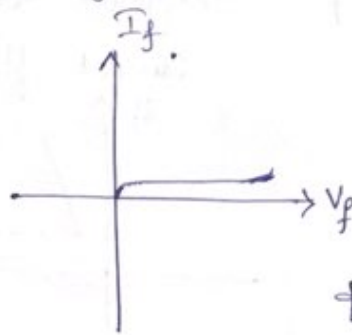
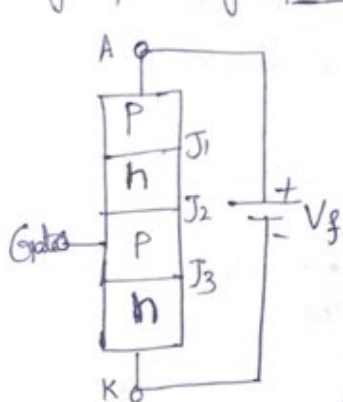
1. Reverse blocking mode.
2. forward blocking mode
3. forward conduction mode.

① Reverse blocking mode: SCR is operated in Reverse blocking mode by providing negative voltage across Anode & Cathode.



- It is observed that, in this mode J₁ is Reverse biased, J₂ is forward biased, J₃ is Reverse biased.
- As J₁ & J₃ are reverse biased, there exist a small leakage current called "reverse leakage current".
- If $(-V_e)$ voltage is further increased then J₁ & J₃ junction breakdown and hence current increases rapidly.
- The $(-V_e)$ voltage at which J₁ & J₃ junctions breakdown and current rises rapidly is known as "Reverse breakdown voltage (V_{BR})". → It is considered as OFF mode of SCR.

② Forward blocking mode: SCR is operated in forward blocking mode by providing positive voltage across anode & cathode.



→ J₁, J₃ are forward biased and J₂ is reverse biased.

→ As J₁, J₃ are forward biased there exist a small amount of current called "forward leakage current".

→ This mode is considered as OFF mode of SCR

③ Forward conduction mode: SCR can be operated in forward conduction mode by following any of these two ways

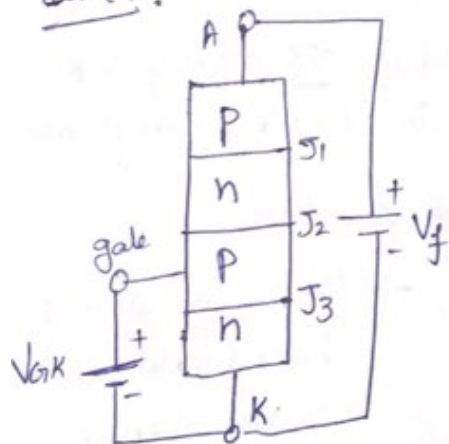
Case (1) ① By increasing forward voltage V_f till forward breakover voltage (V_{BO}).

Case (2) ② By providing positive voltage b/w gate & cathode by retaining V_f .

Case (1):
forward breakover voltage: The forward voltage V_f at which J_2 junction breaks down and SCR changes its state from OFF to ON is called "forward breakover (V_{BO}) voltage".

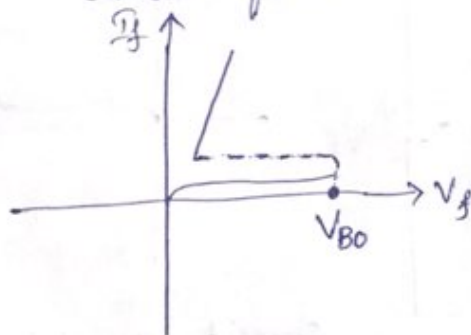
→ At forward breakover voltage SCR goes from forward blocking mode to forward conduction mode.

Case (2):



→ By applying (+ve) V_{GK} along with (+ve) V_f , all junctions J_1, J_2, J_3 are forward biased.

→ Hence SCR turns ON and current flows linearly.



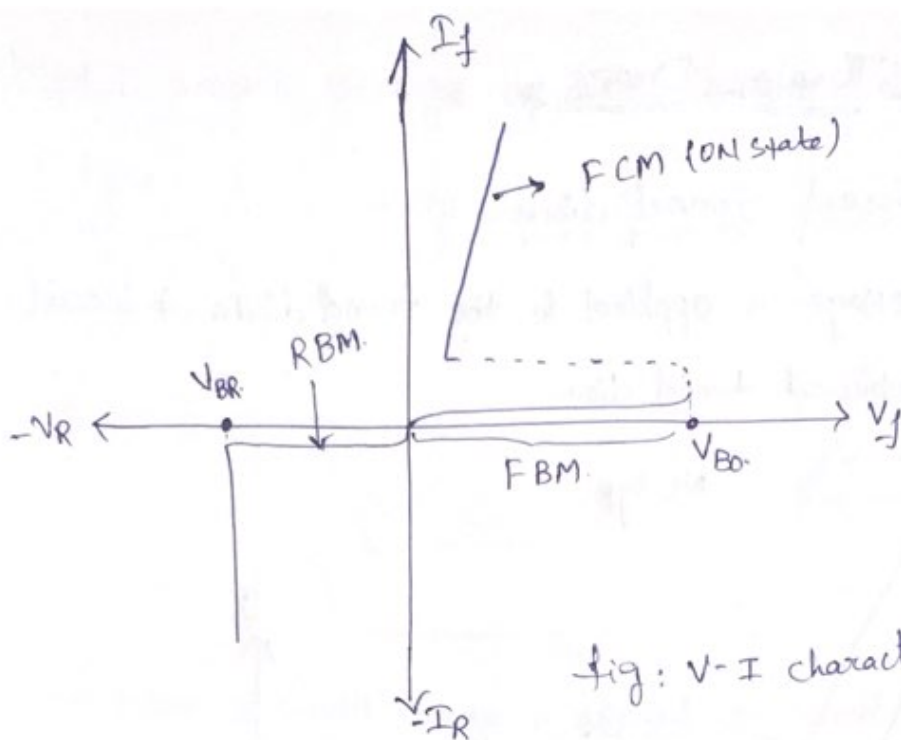


Fig: V-I characteristics of SCR.

Tunnel diode :- It is a heavily doped pn-junction diode in which electric current decreases as the voltage increases. i.e. it exhibits "negative resistance" in a certain region when it is forward biased.

→ A tunnel diode is also known as "ESAKI DIODE".

→ ~~Tunnel diode is a heavily doped PN junction~~ Symbol:

→ The heavily doped PN junction is almost 1000 times greater than in normal diode.

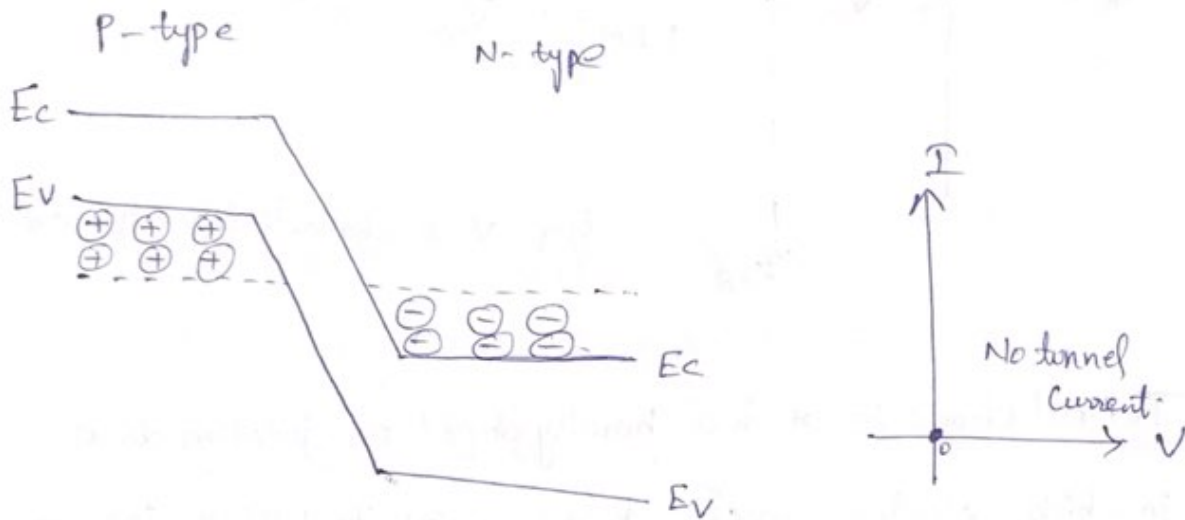
→ Tunnel diode is used as a very fast switching device in Tunneling effect (or) Tunneling:

→ As tunnel diode is heavily doped, depletion layer width is of very small. Thus conduction band of n-type & valence band of p-type overlaps. As a result, for a small applied voltage, electrons of n-type conduction band tunnel to p-type valence band. This is called "Tunneling".

WORKING OF TUNNEL DIODES

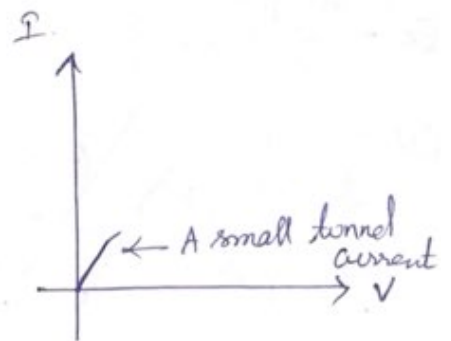
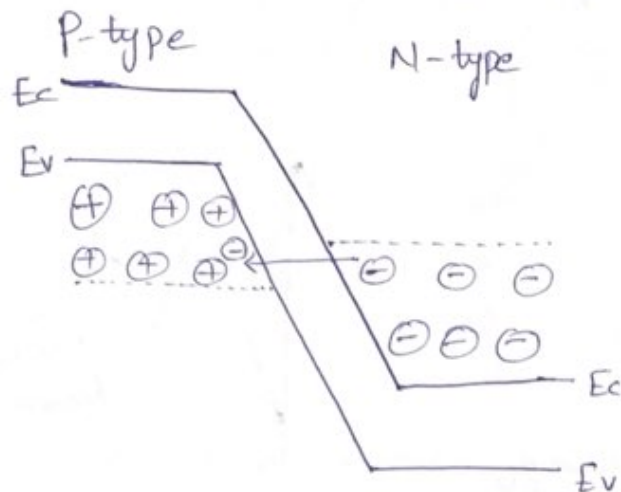
Step 1: unbiased tunnel diode:

When no voltage is applied to the tunnel diode, it is said to be an unbiased tunnel diode.



- In tunnel diode, the conduction band of n-type sc overlaps with valence band of p-type sc due to heavy doping.
- Because of this overlapping the conduction band electrons at n-side and valence band holes at p-side are nearly at the same energy level.
- So some e^- s tunnel from conduction band of n-side to valence band of p-side, & holes tunnel from valence band of p-side to conduction band of n-side.
- Hence the net current flow is zero, as equal no: of e^- s & holes flow in opposite direction.

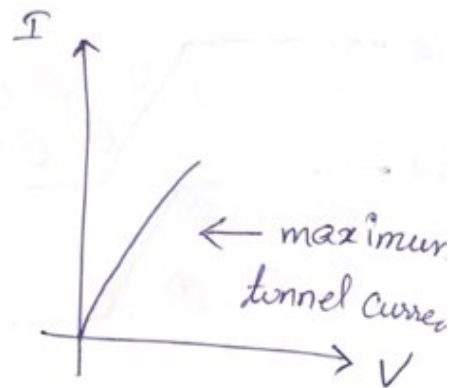
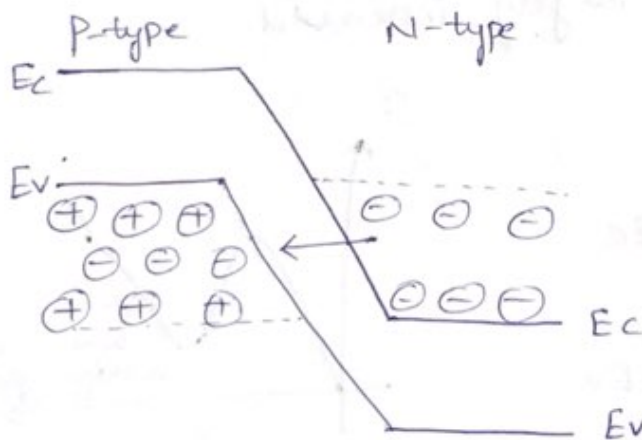
Step 2: small voltage applied to tunnel diode.



→ When a small voltage is applied to tunnel diode, a small no. of e^- s in conduction band of n-type will tunnel to valence band in p-type.

→ Hence a small amount of tunnel current starts flowing.

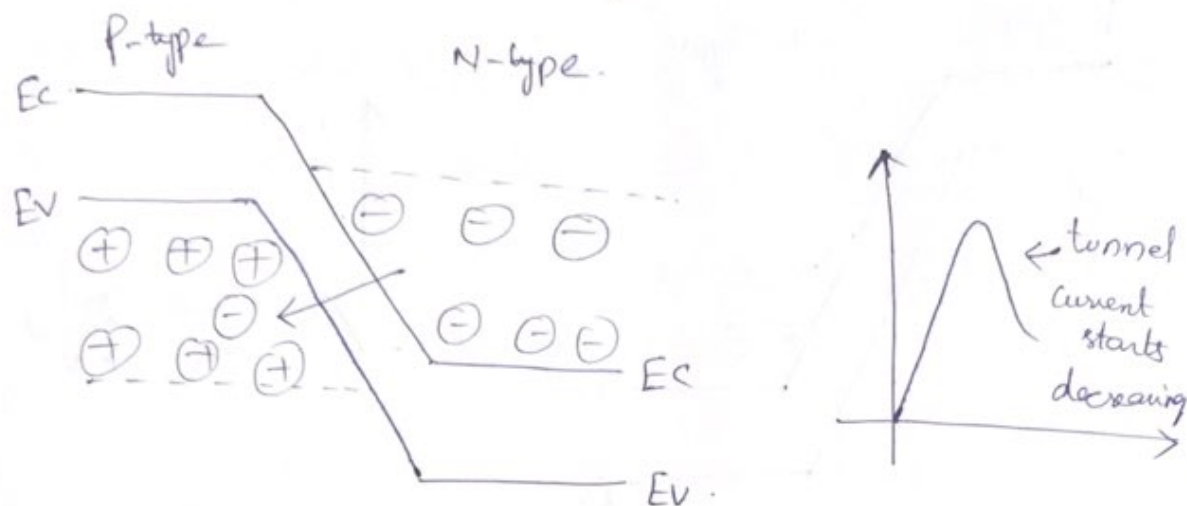
Step 3: Applied voltage is slightly increased.



→ When applied voltage is increased, a large no. of free electrons at n-side conduction band tunnel to valence band in p-type. As a result maximum tunnel current flows.

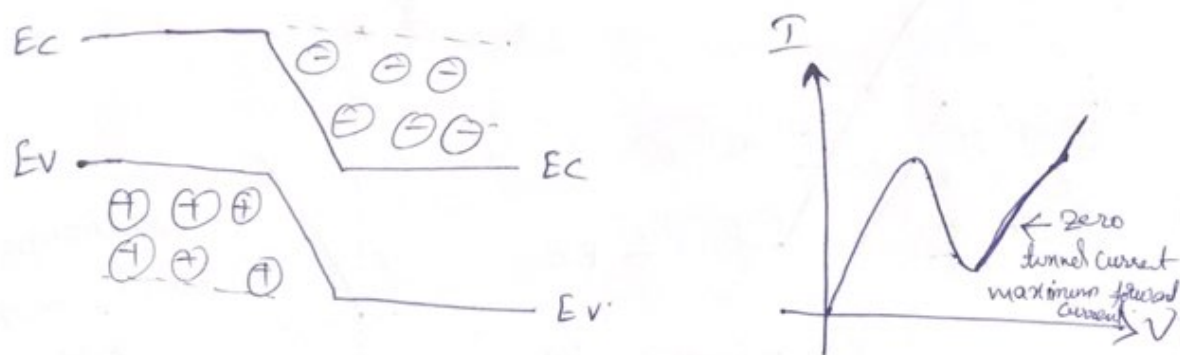
→ energy level of n-side conduction band =
energy " " p-side valence band.

Step 4: Applied voltage is further increased.

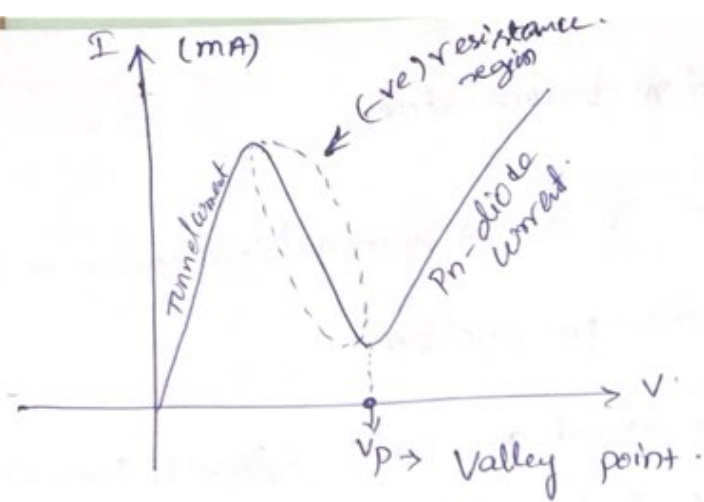


- If the applied voltage is further increased, a slight misalignment of conduction band and valence band takes place.
- Very few e^- s tunnel from n-type conduction band to P-type valence band. Thus, the tunneling current starts decreasing.

Step 5: Applied voltage is largely increased.



- If applied voltage is largely increased then tunneling current drops to zero.
- At this point, the conduction band & valence band no longer overlap and the tunnel diode operates same as p-n diode.



V-I Characteristics

- The region in which current decreases with increase in voltage is called "(-ve) resistance region".
- The voltage at which tunnel current drops to zero is called "valley point" voltage.
- Tunnel diode operating in (-ve) resistance region can act as an amplifier or an oscillator.

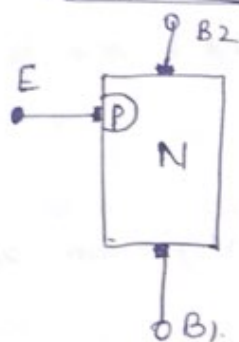
UJT : unijunction transistor

→ Definition: It is a 3 terminal semiconductor device, which has only one pn-junction.

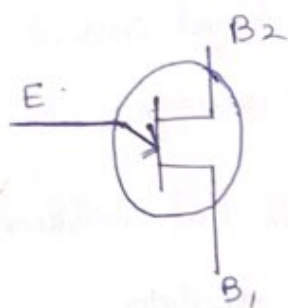
* 3 terminals are named as Emitter, base 1, base 2.

* As it has only 1 junction, it is called as "unijunction transistor".

Construction



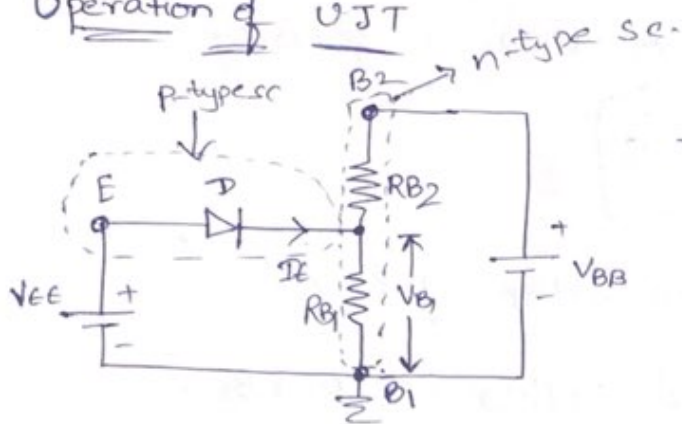
Symbol



→ UJT is constructed with a base substrate of n-type semiconductor, into which heavily doped p-type sc is diffused close to base 2.

→ Arrow mark on Emitter terminal indicates that, maximum amount of current flows from emitter towards base 1 terminal.

Operation of UJT



Case (1): with emitter terminal open.

→ if $V_{EE} = 0$ and if V_{B1} reverse bias the diode then $I_E = 0$.

→ But due to minority carriers, there is a small leakage current flowing from B_2 to E .

Case (2): When a (+ve) V_{EE} is applied to emitter:

→ If V_{EE} is applied in such a way that, it should be more than cut-in voltage of diode as well as voltage across R_{B1} (V_{B1}), then diode D is forward biased.

→ When diode is forward biased, emitter injects holes into n-type SC bar.

→ These holes are repelled by B_2 (as R_{B2} is provided w (+ve) voltage) and are attracted by B_1 (as R_{B1} is provided with (-ve) voltage).

→ Hence there exist large amount of current flow from emitter towards base 1 (B_1). As a result R_{B1} reduces.

→ UJT is limited by V_E .

→ peak voltage (V_p) of UJT is given by

$$V_p = \eta V_{BB} + V_D$$

V_D → cut-in voltage of diode.

V_{BB} → Applied voltage b/w B_1 & B_2 .

** η → intrinsic stand-off ratio

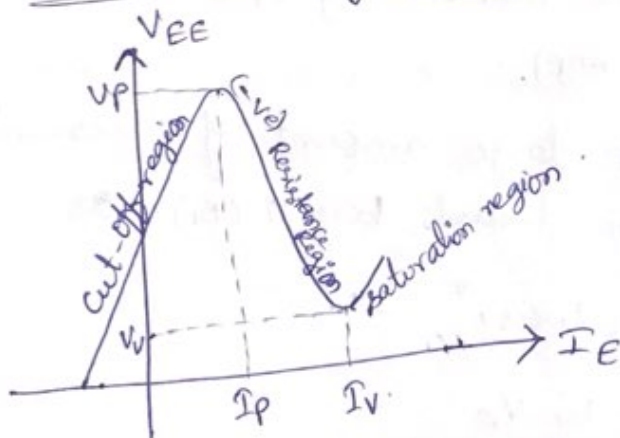
$$\eta = \frac{R_{B1}}{R_{B1} + R_{B2}} \approx 0.5 \text{ to } 0.75$$

$$V_{BB} = \frac{V_{B1}}{\eta}$$

Case (3): When (-ve) voltage is applied to Emitter.

→ Diode is reverse biased and hence UJT is in off condition.

Characteristics of UJT:



V_v → valley point.

Cut-off Region:

for $V_{EE} < V_p$,

Emitter is reverse biased and hence there will be small leakage current.

→ practically UJT is in OFF state.

→ This region is known as Cut-off region.

(-ve) Resistance Region:

if $V_{EE} > V_P$, then diode is forward biased.

→ It increases I_E and decreases R_{BI} thereby decreasing V_{EE} .

$$I_E \propto \frac{1}{R_{BI}} \Rightarrow \text{Negative resistance.}$$

[from $V = IR$, if $R \downarrow$, then $V \downarrow$,
(rough) so V_{EE} decreases with \downarrow in R_{BI}].

→ The region in which I_E increases with decrease in V_{EE} is called

(-ve) Resistance Region

Saturation Region

→ The region after valley point is called saturation region.

Varactor diode:

→ Varactor diode is originated from Variable capacitor
pn-junction

→ The diode which operates only in reverse bias, and whose capacitance can be varied w.r.t reverse bias voltage is called as "Varactor diode".

→ It is also called as Varicap diode, Tuning diode, Variable reactance diode, Variable capacitance diode.

→ Symbol:  Cathode.

$$\rightarrow \text{junction capacitance } C_j = C_0 \left[1 + \frac{V_R}{V_B} \right]^{-n} = \frac{C_0}{\left[1 + \frac{V_R}{V_B} \right]^n}$$

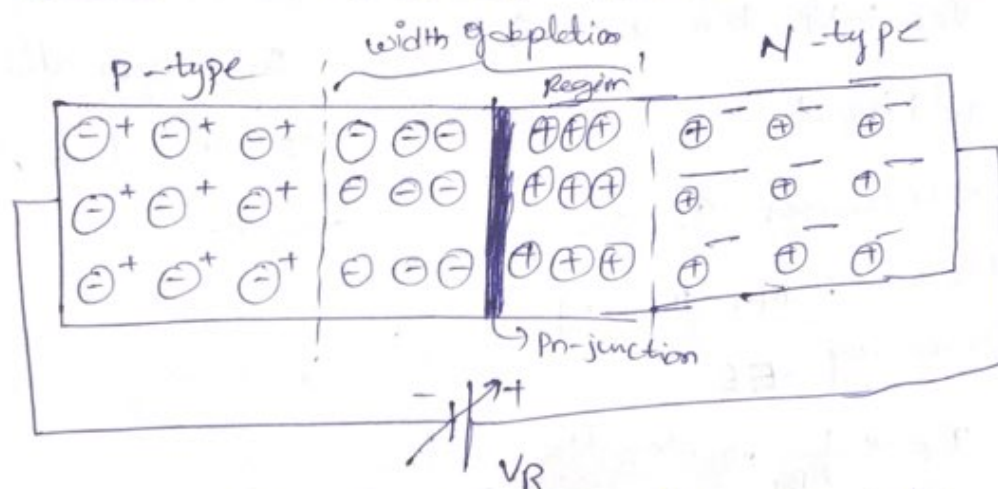
C_0 → capacitance at zero biasing.

V_R → Reverse bias voltage.

V_B → barrier voltage

$$C_j \propto \frac{1}{V_R}$$

Working principle (or) principle of operation:



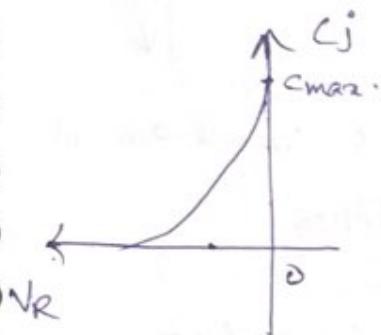
- When reverse bias is applied to a diode, then holes from p-side & electrons from n-side move away from the junction.
- This process increases the width of the depletion region.
- Depletion region acts as an insulator (or) dielectric material.
- Width of depletion region is controlled by reverse bias voltage.
- Thus the diode is used as a ~~variable~~ voltage variable capacitor.
- WKT, junction capacitance

$$C_j = \frac{C_0}{\left[1 + \frac{V_R}{V_B}\right]^n}$$

$$C_j \propto \frac{1}{V_R}$$

→ If reverse voltage increases then depletion region width increases which reduces the capacitance

→ Thus reverse voltage must be maintained at minimum value to have maximum capacitance.



→ Graph depicts that if reverse voltage increases then junction capacitance decreases.

Photo diode :- A pn junction semiconductor device that consumes light energy to generate electric current is termed as "photo diode".

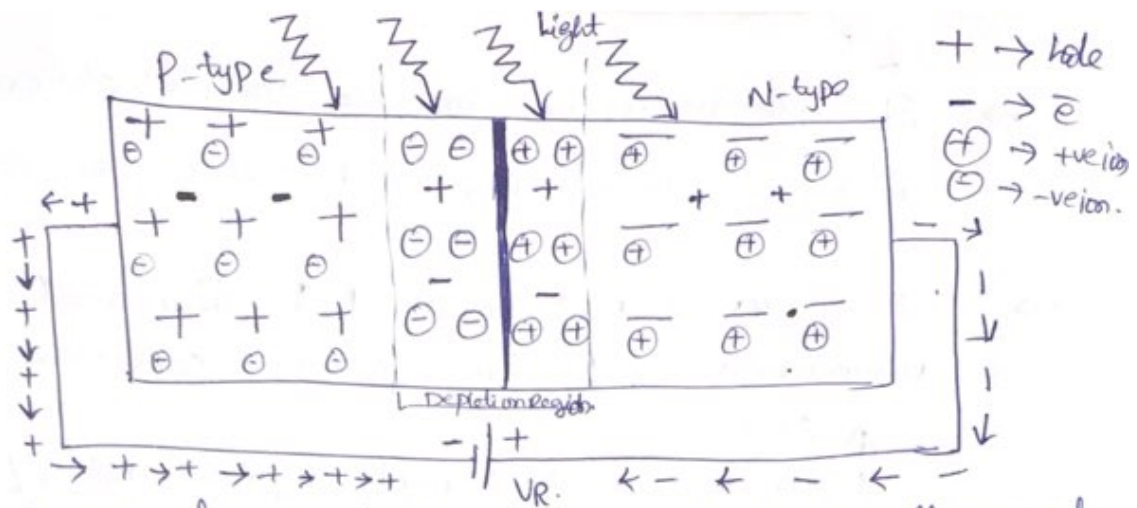
→ It is also called as photo detector, photo-sensor, light detector.

→ Symbol : 

→ Arrow marks represent light (or) photons.

Working principle (or) principle of operation :-

→ Photodiodes are specially designed to operate in reverse bias condition.



\rightarrow A normal pn-junction diode allows small amount of current under reverse bias condition.

\rightarrow To increase current in reverse bias condition, we need to generate more minority carriers.

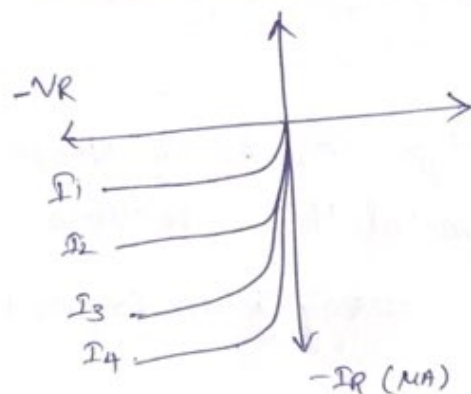
\rightarrow Applied reverse voltage supply energy to minority charge carriers but not increase the no. of minority charge carriers.

$\xrightarrow{**}$ To overcome this problem, we need to apply external energy directly to depletion region to generate more charge carriers.

$\xrightarrow{**}$ Photo diode is designed to generate more no. of charge carriers in depletion region.

$\xrightarrow{**}$ In photo diodes, we use light (or) photons as external energy to generate charge carriers in depletion region.

V-I characteristics

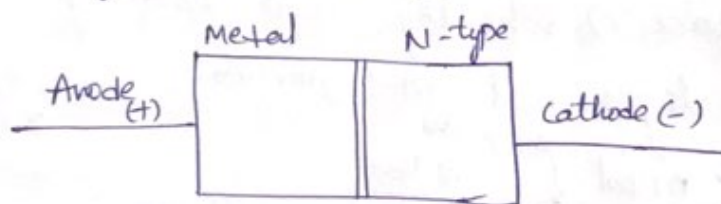


Schottky Diode :- It is a metal-semiconductor junction diode that has less forward voltage drop than P-N junction diode and can be used in high-speed-switching applications.

→ It is also called as surface barrier diode, hot-electron diode, hot carrier diode.

Symbol: Anode Cathode.

Construction :- In the construction of Schottky a Metal-Semiconductor (M-S) junction is formed b/w a metal & an n-type semiconductor.



Case(1): No biasing.

→ Both in metal & N-type sc the majority charge carriers are electrons.

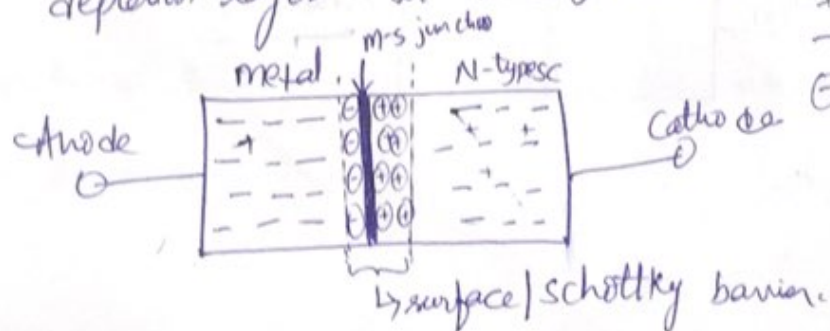
→ When metal is joined with N-type sc, e^- s of N-type sc start moving towards the metal, this is because e^- s of N-type sc have more energy when compared with e^- s of metal.

→ Thus these injected e^- s are called as hot carriers and hence it is also called as hot carrier diode (or) hot e^- diode.

→ In schottky diode the flow of current is due to majority carriers (e^- s) hence schottky diode is a unipolar device.

→ Heavy flow of e^- s into metal creates a region near the M-S junction. And this region contains -ve ions on metal side & more (+ve) ions on N-type sc. And it is called as surface barrier (or) schottky barrier.

→ surface (or) schottky is a kind of depletion layer at M-S junction.



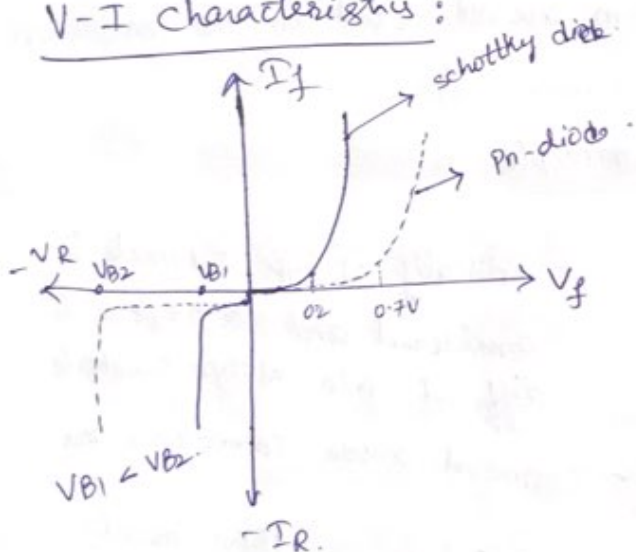
→ schottky/surface barrier opposes the flow of e^- from N-type to metal.

→ so, we need to provide biasing.

Case (2): with biasing.

→ When forward biasing is applied by connecting metal to (+ve) terminal & N-type sc to (-ve) terminal of battery then due to force of repulsion e^- of N-type sc cross the schottky barrier and move into metal side. Thereby resulting large amount of current flow.

V-I Characteristics:



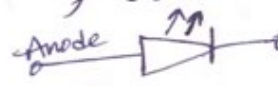
→ V-I characteristics of Schottky diode is almost similar to P-N junction diode.

→ The forward voltage drop (cut-in-voltage) of schottky diode is of the order of 0.2V.

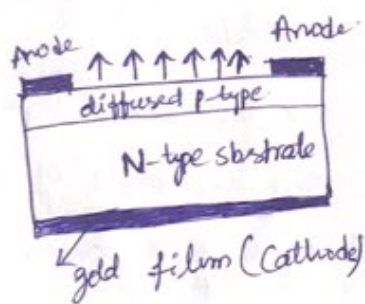
→ In schottky diode, the reverse saturation current occurs at very low voltage as compared to P-N junction diode.

LED : Light Emitting Diode

It is a PN-junction diode which emits light when an electric current passes through it in forward direction.

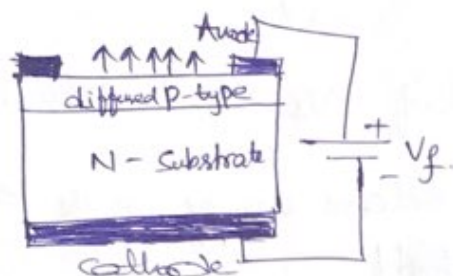
- Amount of light emitted \propto forward current
- LED is made of semiconductor ^{compound} material, and the light is emitted through the junction of the diode.
_{radiated}
- Semiconductor compound materials can be Gallium Arsenide (GaAs) Gallium phosphide (GaP) etc.
- Symbol : 
- * → Silicon & Germanium are not used in the construction of LED.

Construction & Working principle



- Initially N-type substrate is considered and a p-type sc is diffused onto N-type substrate.
- metal anode connections are made at the outside of diffused P-type sc. These metal anode connections are made in such way that more central surface is made available for the light to escape.
- Gold film is applied at bottom of substrate to act as Cathode.

WORKING: LED must be forward biased to understand the working principle.



→ The process of obtaining light energy by providing an electrical voltage is called "electro-luminescence".

→ When forward voltage is applied, then forward current is produced.

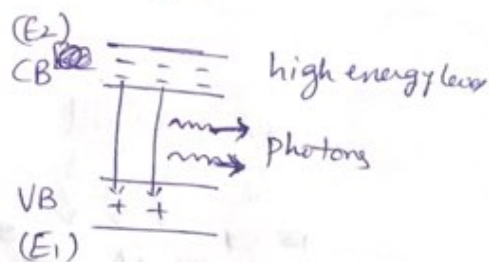
→ This forward current is due to electrons.

→ In LED, electrons of N-type are in higher conduction band & holes of P-type are in lower valence band.

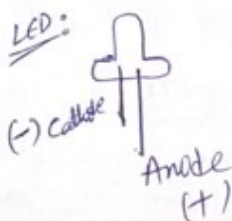
** → When current flows through diode, then recombination of electrons & holes takes place. i.e., electrons

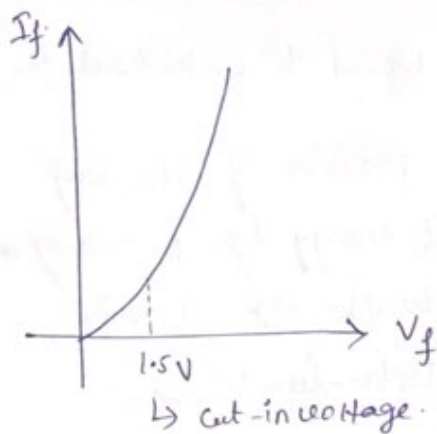
~~move~~ move from higher energy level to lower energy level and releases the photons.

** → These photons will have a wave length of energy difference $[E_2 - E_1]$



** → The energy difference can be either in the form of heat (or) in the form of light.





V-I characteristics

→ cut-in voltage of LED is 1.5V

→ if $V_f > 1.5V$ then LED release energy in the form of light.

→

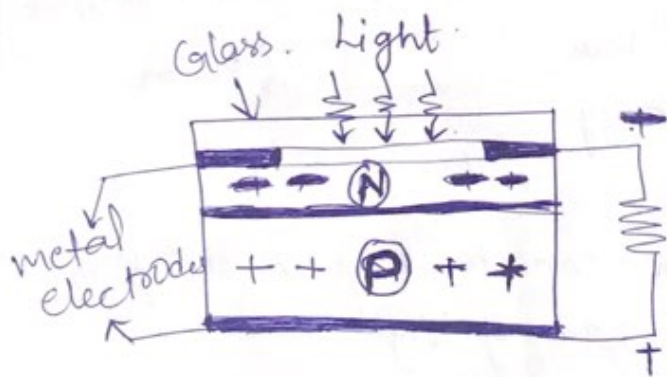
Solar cell: It is a p-n junction device which converts solar ^{light} energy into electrical energy.



→ it is also called Photo-voltaic cell

→ It works on the principle called "photo-voltaic effect".

Construction:



→ Initially P-type SC is considered.

→ A thin layer of N-type SC is diffused into P-type SC.

→ on top of N-type SC, metal layer is developed in such a way that; more central space is made available for light to inject. → Glass avoids mechanical shock.

- Another metal layer is developed at bottom of p-type sc.
- metal layer at N-type sc acts as ~~Anode~~ ^{Cathode} & " " " p-type " " " ~~Cathode~~ ^{Anode}.

Working : When light is incident on pn-junction then electron-hole pairs are generated.

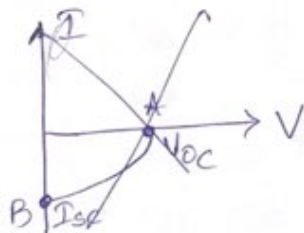
→ due to junction field (or) electric field at junction holes move towards p-type & e^- s move toward N-type sc.

→ These electrons & holes are collected at two side of junction.

→ These photogenerated e^- s & holes develop photo voltage at both the metal layers of p-type & N-type sc.

→ When external load is connected across metal layers then photo current flows through ~~the~~ load.

V-I characteristics



→ V-I characteristics lies in 4th quadrant.

→ ~~This is because~~ ^{**} solar cell doesn't draw current but supplies current.

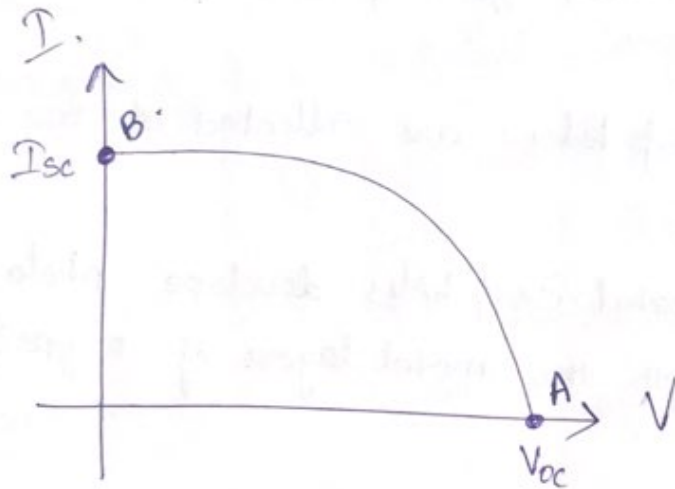
→ 'A' represents open circuit voltage

→ 'B' represents short ckt current.

Photo-voltaic effect : The effect, in which current/voltage is generated when exposed to light. Through this effect solar cells convert sunlight into electrical energy.

* each solar cell generally 0.5V of voltage.


* Solar panel is the combination of many solar cells.







→ V_{oc} , Voltage when no load is connected (Current is minimum)

→ I_{sc} , Short ckt current when load is connected (Current is maximum).

Adv

Device	Advantages	Disadvantages	Applications
Zener diode 	<ul style="list-style-type: none"> → High accuracy → Small size → Low cost 	<ul style="list-style-type: none"> → Lower regulation ratio → Can't handle high-power 	<ul style="list-style-type: none"> → Voltage Regulators → Clipping & clamping ckt's → switching applications
LED 	<ul style="list-style-type: none"> → long life → Reliability → high intensity of brightness. 	<ul style="list-style-type: none"> → Temperature dependence → Light quality → Voltage sensitivity 	<ul style="list-style-type: none"> → motorcycles & cars → home appliances → traffic light signals.
Photo diode. 	<ul style="list-style-type: none"> → less resistance → long life → less noise 	<ul style="list-style-type: none"> → less sensitivity → Temperature dependence → Active area is small 	<ul style="list-style-type: none"> → Consumer electronics → medical applications → optical communication
VJT 	<ul style="list-style-type: none"> → low cost → (-ve) resistance characteristic → low power absorbing device 	<ul style="list-style-type: none"> → Inability to provide appropriate amplification 	<ul style="list-style-type: none"> → timing ckt's → relaxation oscillator → voltage detector
SCR 	<ul style="list-style-type: none"> → easy to turn on → low cost → Can handle large voltages, currents & power 	<ul style="list-style-type: none"> → Can't be easily turn off → low switching speed → Can't be used at high frequencies 	<ul style="list-style-type: none"> → Choppers. → Inverters → Battery chargers.

Device	Advantages	Disadvantages	Applications
Varactor diode 	<ul style="list-style-type: none"> → Less noise → Light weight → Reliability 	<ul style="list-style-type: none"> → Can't operate in forward bias mode. 	<ul style="list-style-type: none"> → Voltage controlled oscillators → RF filters → Frequency & Phase modulators
Schottky diode 	<ul style="list-style-type: none"> → Low turn on voltage → Low junction capacitance → Low voltage drop. 	<ul style="list-style-type: none"> → Reverse leakage current → Low reverse voltage rating 	<ul style="list-style-type: none"> → Switched-mode power supplies → reverse current protection → RF mixers & detector.
solar cell 	<ul style="list-style-type: none"> → No pollution associated with it → No maintenance cost → Long life 	<ul style="list-style-type: none"> → high cost of installation → low efficiency. 	<ul style="list-style-type: none"> → Provides electricity for → water pumps → laptop → computers
Tunnel diode 	<ul style="list-style-type: none"> → Low cost → Durable → Suitable for high-frequency, speed applications 	<ul style="list-style-type: none"> → Not possible to fabricate tunnel diodes on large scale → Swing in opp. → Low-power device. 	<ul style="list-style-type: none"> → In digital kits → Frequency converter.

- ① Draw energy band diagram of tunnel diode & explain tunneling phenomenon. Draw $V-I$ characteristics. [OR]
- ② What is tunneling phenomena? Explain principle of operation of tunnel diode with its characteristics [OR] with the help of energy band diagram explain tunneling phenomenon in tunnel diode.
- ② Define Varactor diode? Explain operation of Varactor diode with its circuit and mention applications
- ③ How and under what conditions Zener breakdown take place in diode? Draw $V-I$ characteristics of Zener diode and show the breakdown region.
- ④ Explain in detail about principle of operation of SCR.
- ⑤ Explain the construction & characteristics of UJT.
- ⑥ prove the statement "A Zener diode can act as voltage regulator".
- ⑦ Draw the symbols of all special purpose devices along with their definitions.

EDC- ASSIGNMENT-5